## SI

# **Design of Experiments**



Figure S1. Definition of the hole diameters and spacings used in figure 2. Scale bars are 10  $\mu$ m.

Factorial Regression: Height versus Diameter, Spacing, Growth time

Stepwise Selection of Terms

 $\alpha$  to enter = 0.1,  $\alpha$  to remove = 0.1

Analysis of Variance

Source	DF	Seq SS	Contribution	Adj SS	Adj MS	F-Value	P-Value
Model	1	4588.8	77.83%	4588.8	4588.84	49.14	0.000
Linear	1	4588.8	77.83%	4588.8	4588.84	49.14	0.000
Growth time	1	4588.8	77.83%	4588.8	4588.84	49.14	0.000
Error	14	1307.3	22.17%	1307.3	93.38		
Lack-of-Fit	6	161.0	2.73%	161.0	26.83	0.19	0.972
Pure Error	8	1146.3	19.44%	1146.3	143.29		
Total	15	5896.1	100.00%				

Model Summary

S	R-sq	R-sq(adj)	PRESS	R-sq(pred)
9.66311	77.83%	76.24%	1707.44	71.04%

Regression Equation in Uncoded Units





Factorial Regression: Wall thickness versus Diameter, Spacing, Growth time

Stepwise Selection of Terms

 $\alpha$  to enter = 0.1,  $\alpha$  to remove = 0.1

The stepwise procedure added terms during the procedure in order to maintain a hierarchical model at each step.

Analysis of Variance

							Р-
	D		Contributi		Adj	F-	Valu
Source	F	Seq SS	on	Adj SS	MS	Value	e
Model	7	5.3373	90.11%	5.3373	0.7624	10.42	0.00
		5		5	8		2
Linear	3	3.0433	51.38%	3.0433	1.0144	13.86	0.00
		0		0	3		2
Diameter	1	0.7467	12.61%	0.7467	0.7467	10.20	0.01
		1		1	1		3
Spacing	1	2.2963	38.77%	2.2963	2.2963	31.37	0.00
		6		6	6		1
Growth time	1	0.0002	0.00%	0.0002	0.0002	0.00	0.95
		3		3	3		7
2-Way Interactions	3	0.9747	16.46%	0.9747	0.3249	4.44	0.04
		1		1	0		1
Diameter*Spacing	1	0.2760	4.66%	0.2760	0.2760	3.77	0.08
		2		2	2		8
Diameter*Growth time	1	0.4480	7.56%	0.4480	0.4480	6.12	0.03
		6		6	6		8
Spacing*Growth time	1	0.2506	4.23%	0.2506	0.2506	3.42	0.10
		3		3	3		1
3-Way Interactions	1	1.3193	22.28%	1.3193	1.3193	18.03	0.00
		4		4	4		3

Diameter*Spacing*Growth	1	1.3193	22.28%	1.3193	1.3193	18.03	0.00
time		4		4	4		3
Error	8	0.5855	9.89%	0.5855	0.0731		
		5		5	9		
Total	15	5.9229	100.00%				
		0					

Model Summary

S	R-sq	R-sq(adj)	PRESS	R-sq(pred)
0.270543	90.11%	81.46%	2.34219	60.46%

Regression Equation in Uncoded Units

Wall = 2.552 - 0.1614 Diameter - 0.244 Spacing - 0.768 Growth time thickness + 0.02363 Diameter\*Spacing + 0.0463 Diameter\*Growth time + 0.1208 Spacing\*Growth time -

0.00766 Diameter\*Spacing\*Growth time



Factorial Regression: Undamaged cells versus Diameter, Spacing, Growth time

Stepwise Selection of Terms

 $\alpha$  to enter = 0.1,  $\alpha$  to remove = 0.1

The stepwise procedure added terms during the procedure in order to maintain a hierarchical model at each step.

Analysis of Variance

							Р-
	D	Seq	Contributi	Adj		F-	Valu
Source	F	SS	on	SS	Adj MS	Value	e
Model	7	1.6099	96.22%	1.6099	0.22999	29.10	0.00
		7		7	5		0
Linear	3	1.0504	62.78%	1.0504	0.35015	44.31	0.00
		6		6	5		0
Diameter	1	0.8235	49.22%	0.8235	0.82358	104.22	0.00
		8		8	3		0
Spacing	1	0.1556	9.30%	0.1556	0.15563	19.69	0.00
		3		3	3		2
Growth time	1	0.0712	4.26%	0.0712	0.07124	9.02	0.01
		5		5	8		7
2-Way Interactions	3	0.3833	22.91%	0.3833	0.12776	16.17	0.00
		1		1	9		1
Diameter*Spacing	1	0.1447	8.65%	0.1447	0.14474	18.32	0.00
		5		5	6		3
Diameter*Growth time	1	0.0669	4.00%	0.0669	0.06693	8.47	0.02
		3		3	0		0
Spacing*Growth time	1	0.1716	10.26%	0.1716	0.17163	21.72	0.00
		3		3	1		2
3-Way Interactions	1	0.1761	10.53%	0.1761	0.17619	22.30	0.00
		9		9	5		1

Diameter*Spacing*Growth	1	0.1761	10.53%	0.1761	0.17619	22.30	0.00
time		9		9	5		1
Error	8	0.0632	3.78%	0.0632	0.00790		
		2		2	3		
Total	15	1.6731	100.00%				
		9					

Model Summary

S	R-sq	R-sq(adj)	PRESS	R-sq(pred)
0.0888970	96.22%	92.92%	0.252886	84.89%

Regression Equation in Uncoded Units

Undamaged = -0.168 + 0.0589 Diameter + 0.1199 Spacing + 0.3304 Growth time cells - 0.00612 Diameter\*Spacing - 0.01668 Diameter\*Growth time - 0.05569 Spacing\*Growth time

+ 0.002798 Diameter\*Spacing\*Growth time



Factorial Regression: Cracks over 2 to 5 cells v. Diameter, Spacing, Growth time

Stepwise Selection of Terms

 $\alpha$  to enter = 0.1,  $\alpha$  to remove = 0.1

The stepwise procedure added terms during the procedure in order to maintain a hierarchical model at each step.

Analysis of Variance

	D		Contributio			F-	Р-
Source	F	Seq SS	n	Adj SS	Adj MS	Value	Value
Model	3	0.2019	84.60%	0.2019	0.06730	21.98	0.000
		3		3	9		
Linear	2	0.1482	62.11%	0.1482	0.07412	24.20	0.000
		4		4	1		
Diameter	1	0.0969	40.62%	0.0969	0.09696	31.66	0.000
		6		6	3		
Growth time	1	0.0512	21.48%	0.0512	0.05127	16.74	0.001
		8		8	8		
2-Way Interactions	1	0.0536	22.49%	0.0536	0.05368	17.53	0.001
		9		9	6		
Diameter*Growth	1	0.0536	22.49%	0.0536	0.05368	17.53	0.001
time		9		9	6		
Error	12	0.0367	15.40%	0.0367	0.00306		
		5		5	3		
Lack-of-Fit	4	0.0119	5.00%	0.0119	0.00298	0.96	0.479
		2		2	1		
Pure Error	8	0.0248	10.40%	0.0248	0.00310		
		3		3	4		
Total	15	0.2386	100.00%				
		8					

Model Summary

S R-sq R-sq(adj) PRESS R-sq(pred)

0.0553428 84.60% 80.75% 0.0653403 72.62%

**Regression Equation in Uncoded Units** 

Cracks over 2 to 5 = 0.5257 - 0.02583 Diameter - 0.0766 Growth time cells + 0.003862 Diameter\*Growth time



#### Hydrothermal synthesis

*Experimental section for Hydrothermal syntheses.* Following a published protocol for olivelike bismuth vanadate (BiVO<sub>4</sub>) nanostructures,[38] solutions of 1 mmol bismuth nitrate pentahydrate (Bi(NO<sub>3</sub>)<sub>3</sub>, Sigma Aldrich) in 30 mL EG and 1 mmol ammonium metavanadate (NH<sub>4</sub>VO<sub>3</sub>, Sigma Aldrich) in 10 mL DI-water are prepared and stirred for 30 minutes. Then 5 mL of the vanadium precursor and 15 mL of the bismuth precursor are filled into a teflon liner for the microwave reactor. To introduce hydrophilicity and reactive groups, the CNT honeycomb structures on the Si-wafer chips are treated with UV-ozone for 30 minutes and then slowly put into the solution. The liners are put into the microwave and heated to 140 °C for 4 hours. Afterwards the solution is filtered using vacuum filtration and the CNT structure is washed multiple times with DI-water. The filtered particles and the coated structure are dried at 80 °C overnight. Adapting the first published, hydrothermal protocol for bismuth vanadate (BiVO<sub>4</sub>),[37] solutions of 1 mmol bismuth nitrate pentahydrate (Bi(NO<sub>3</sub>)<sub>3</sub>, Sigma Aldrich) in 20 mL DI-water and 1 mmol sodium vanadium oxide (NaVO<sub>3</sub>) are prepared. NaVO<sub>3</sub> is prepared by dissolving 39.997 mg NaOH in 20 mL DI-water and adding 9.09 mg vanadium(V)oxide (V<sub>2</sub>O<sub>5</sub>, Sigma Aldrich). All solutions are stirred for 30 minutes and then mixed together. The pH is adjusted to 7 using NaOH. Then 20 mL of the mixed precursor solution is filled into a Teflon liner for the microwave reactor. To introduce hydrophilicity and reactive groups, the CNT honeycomb structures on the Si-wafer chips are treated with UV-ozone for 30 minutes and then slowly put into the solution. The liners are put into the microwave and heated to 140 °C for 3 hours. Afterwards the solution is filtered using vacuum filtration and the CNT structure is washed multiple times with DI-water. The filtered particles and the coated structure are dried at 80 °C overnight. The concentration is lowered to 1/10 for some experiments.

Following а published protocol for hierarchical bismuth vanadate (BiVO<sub>4</sub>) nanostructures, [36] a solution of 0.5 mmol bismuth nitrate pentahydrate (Bi(NO<sub>3</sub>)<sub>3</sub>, Sigma Aldrich) and 0.5 mmol ammonium metavanadate (NH<sub>4</sub>VO<sub>3</sub>, Sigma Aldrich) in 40 mL ethylene glycol (EG, Acros Organics) is prepared and stirred for 10 minutes. Then 20 mL each of the solution are filled into two teflon liners for the microwave reactor. To introduce hydrophilicity and reactive groups, the honeycomb structures on the Si-wafer chips are treated with UV-ozone for 30 minutes and then slowly put into the solution. The liners are put into the microwave and heated to 140 °C for one hour. Afterwards the solution is filtered using vacuum filtration and the CNT structure is washed multiple times with DI-water. The filtered particles and the coated structure are dried at 80 °C overnight.

### Results:



**Figure S2.** A microwave-assisted, hydrothermal synthesis following a protocol by Shang et al.[36] is used to synthesize particles on the CNT surface, SEM images are shown in a and b

with some nucleation but no uniform coating, and XRD measurements (c) confirm a different composition of bismuth vanadium oxide (c), not the desired BiVO<sub>4</sub>.



**Figure S3.** The hydrothermal, microwave-assisted protocol by Liu et al.[37] shows a large amount of nanoparticles that cover the CNT honeycomb structure (a), coat the sidewalls (b) and are of the desired composition, monoclinic  $BiVO_4$  (c). A decrease in concentration leaves the CNT honeycombs intact (d, e), but doesn't lead to much nucleation and thus no uniform coating on the sidewalls (f).



**Figure S4.** After the microwave-assisted, hydrothermal synthesis adapted from Ma et al.[38] half of the structure is nicely coated, whereas other parts are not coated at all (a). The composition of the particles from this reaction is monoclinic  $BiVO_4$  (b).

# **Hot-casting**



**Figure S5.** A chipped substrate wafer that shows the coating is also on the inside of the CNT walls.



**Figure S6.** An EDX measurement of the chipped substrate wafer to determine the location of specific elements.



**Figure S7.** CV measurement (100 mV/s) in the dark and under irradiation, for an additional sample with exceptionally good performance. Current ranges in the samples shown in the manuscript are more representative for the performances we measured in most samples.



**Figure S8.** CV measurement (100 mV/s) in the dark and under irradiation, for another sample where delamination of the CNTs is observed, causing progressively worse performance. Remaining activity is attributed to the Au layer, which shows no photoresponse.